

The 8th Forum on the Science and Technology of Silicon Materials 2018

November 18-21, 2018 50th Anniversary Hall, Okayama University, Okayama, Japan

Timetable

Monday 19th November		Tuesday 20th November		Wednesday 21th November	
8:30	Opening address	8:30	Session-III: Power Devices and Materials Chair: H. Kaneta, H. Yamamoto	8:30	Session V: Silicon-Related Materials & Solar Cells Chair: S. Binetti, K. Tanahashi
8:45 - 9:15	In Remembrance of Prof. Jan Vanhellemont Chair: K. Sueoka, T. Taishi	8:30 - 9:10 9:10 - 9:50 9:50 - 10:20 10:20 - 10:50	S3-1 H. Kubota (Kumamoto Univ.) S3-2 G. Wachutka (Tech. Univ. of Munich) S3-3 S. Nishizawa (Kyushu Univ.) S3-4 T. Minato (Mitsubishi Electric)	8:30 - 9:10 9:10 - 9:40 9:40 - 10:10 10:10 - 10:40	S5-1 S. Binetti (Univ. of Milano Bicocca) S5-2 A. Ogura (Meiji Univ.) S5-3 K. Kutsukake (Nagoya Univ.) S5-4 T. Suemasu (Tsukuba Univ.)
9:15	Session-I: Silicon Crystals and Wafers Chair: S. Samata, H. Fujimori				
9:15 - 9:55 9:55 - 10:25	S1-1 K. Nakamura (Okayama Pref. Univ.) S1-2 R. Yokoyama (SUMCO)				
10:25	Break	10:50	Break	10:40	Break
10:40	Session-II: Defects, Impurity, Gettering and Characterization Chair: K. Kakimoto, K. Kashima	11:05	Session IV: Post-Silicon Power Devices and Materials Chair: H. Tsuchida, T. Taishi	10:55	Session VI: Imaging Sensor Devices and Materials Chair: K. Kurita, H. Takahashi
10:40 - 11:20 11:20 - 12:00 12:00 - 12:30	S2-1 G. Kissinger (IHP GmbH) S2-2 M. Sluydts (Ghent Univ.) S2-3 T. Horikawa (GlobalWafers Japan)	11:05 - 11:35 11:35 - 12:05 12:05 - 12:35	S4-1 T. Mitani (AIST) S4-2 K. Sasaki (Novel Crystal Technology) S4-3 Y. Ishikawa (JFCC)	10:55 - 11:35 11:35 - 12:05 12:05 - 12:35	S6-1 S. Kawahito (Shizuoka Univ.) S6-2 M. Goto (NHK) S6-3 T. Yamaguchi (Renesas Electronics)
12:30	Lunch	12:35	Group Photo	12:35	Snack
13:30	Session-II: Defects, Impurity, Gettering and Characterization Chair: M. Tajima, N. Fukata	12:40	Excursion	13:00	Session VI: Imaging Sensor Devices and Materials Chair: A. Ogura, T. Shimura
13:30 - 14:10 14:10 - 14:40 14:40 - 15:10 15:10 - 15:40	S2-4 E. Simoen (IMEC) S2-5 R. Sugie (Toray Research Center) S2-6 N. Mitsugi (SUMCO) S2-7 Y. Nagai (GlobalWafers Japan)	12:40 - 18:00		13:00 - 13:30 13:30 - 14:00 14:00 - 14:30	S6-4 Y. Sato (Panasonic) S6-5 T. Shoyama (Canon) S6-6 R. Okuyama (SUMCO)
15:40	Break			14:30	
15:55	Short presentation for Poster Session Chair: S. Murakami, Y. Yamashita			14:30 - 14:45	Closing Remarks
	PA01 X.F. Han PA02 X. Liu PB01 D. Kot PB02 N. Nonoda PB03 K. Tajima PB04 D. Tsuchiya PB05 Y. Ogura PB06 R. Ozaki PB07 R. Hirose PB08 K. Kobayashi PB09 H. Sudo PB10 T. Ide PB11 K. Usuki PB12 Y. Ishikawa	PB13 Y. Ohno PD01 Y. Ohno PD02 T. Subramani PD03 Y. Ohshita PD04 I. Jonoshita PD05 K. Tagawa PD06 T. Yokoi	PD07 K. Ogawa PD08 K. Kawakami PD09 T. Mochizuki PD10 H. Udono PD11 Y. Okamoto PE01 Y. Mukaiyama PE02 S. Shigematsu	PE03 A. Onaka-Masada PE04 W.C.Wen PE05 K. Matsuki PC01 H. Kobayashi PC02 Y. Koga PC03 S. Masuda PC04 Y. Uchida	PC05 N. Tsuchimoto PC06 K. Suzuki PC07 D. Toh PC08 N. Nagai PC09 N. Aida
17:45 17:45 - 19:45 19:45	Poster Session End	18:00 18:00 - 21:00 21:00	Banquet End	14:45	End